



Docket No. NEC03P207-SYa  
(WAK.122)

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re Application of

Hidekazu Kawashima

Serial No.: 10/755,387

Group Art Unit: 2822

Filed: January 13, 2004

Examiner: Maria F. Guerrero

For: METHOD AND DECIDE FOR PRODUCING LAYOUT PATTERNS OF A  
SEMICONDUCTOR DEVICE HAVING AN EVEN WAFER.

Honorable Commissioner of Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

**AMENDMENT UNDER 37 C.F.R. §1.111**

Sir:

In response to the Office Action dated January 10, 2006, please amend the above-identified application as follows:

**INTRODUCTORY COMMENTS**

**Amendments to the Specification** begin on page 2 of this paper.

**Amendments to the Claims** are reflected in the listing of claims which begins on page 4 of this paper. No new matter has been added.

**Remarks** begin on page 9 of this paper.